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## **INFORMATION DISCLOSURE** STATEMENT BY APPLICANT

Complete if Known					
Application Number	Not Yet Assigned				
Filing Date	Even Date Herewith				
First Named Inventor	Hiroshi OGURA et al				
Group Art Unit	1725				
Examiner Name					
Attorney Docket Number	OGURA =1A				

(use as many sheets as necessary) Sheet 1 of 2

			U.S. PA	TENT DOCUMENTS	
Examiner Initials*,	Cite No.1		Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
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		FOREIC	GN PATENT DO	CUMENTS		_
Examiner Initials*	Cite No.1	Foreign Patent Number Country Code <sup>3</sup> Number <sup>4</sup> Kind Code <sup>5</sup> ( <i>it known</i> )	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	⊤°
4m1+	AF	JP 10-029836	2/3/1998	Shinetzu Quartz Prod.Co.		
ŚMH	AG	JP 09-311237	12/2/1997	Kagaku Gijutsu Shinko Jigyodan		
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Examin Signatu		S. Heinrich		Date Considered	1 - 10 - 2004	

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Considered

09-10-2004

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## **INFORMATION DISCLOSURE** STATEMENT BY APPLICANT

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Application Number	Not Yet Assigned				
Filing Date	Even Date Herewith				
First Named Inventor	Hiroshi OGURA et al				
Group Art Unit	1725				
Examiner Name	1				
Attorney Docket Number	OGURA =1A				

	OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS	
Examiner Cite Initials* No.'	Include name of the author (in CAPITAL LETTERS), title of article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published	T <sup>2</sup>
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Examiner Signature	5-Heinrich Date Considered 09-10-2004	

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## Complete if Known Substitute for form 1449A/PTO Application Number 10/713,351 INFORMATION DISCLOSURE November 17, 2003 Filing Date STATEMENT BY APPLICANT Hiroshi OGURA et al First Named Inventor Group Art Unit -1725 (use as many sheets as necessary) Examiner Name \_ Sheet 1 of 1 Attorney Docket Number OGURA=1A

			U.S. PA	TENT DOCUMENTS	
Examiner nitials*	Cite No. <sup>1</sup>	Document Number Number-Kind Code <sup>z (# known)</sup>	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
SMIL	BA	US-5,634,955	June 3, 1997	ARAUJO et al	
SMIT	BB	US-6,563,079 B1	May 13, 2003	UMETSU et al.	
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Examiner Initials*	Cite No.1	Foreign Patent Number Country Code <sup>3</sup> Number <sup>4</sup> Kind Code <sup>3</sup> (# known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	۲ª

		OTHER PRIOR ART - NON PAT		RATURE DOCU	JMENTS	
Examiner Initials*	r Cite magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published					
Smlf	BC RUDOLPH, P. et al., "Femtosecond- and nanosecond-pulse laser ablation of bariumalumoborosilicate glass", Applied Physics A, Materials Science & Processing, December 28, 1999, p S763-S766					
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